IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Tatsuhiko HATANO et al.

Application No.: New U.S. National Stage of PCT/JP2004/017099

Filed: May 16, 2006 Docket No.: 128029

For: HIGH VOLTAGE PULSE GENERATING CIRCUIT

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- 2. Relevance of one or more non-English language reference is discussed in the present specification. See References 17 & 26.
- 3. One or more reference cited herein was cited in the International Search Report. An English language version of the International Search Report is attached for the Examiner's information. See References 16 & 24-25.
- 4. In accordance with 37 CFR §1.98(a)(2)(ii), copies of any U.S. patents and patent application publications are not attached.
- 5. A partial English language Translation of one or more non-English language reference is attached hereto. See Reference 30.
- 6. An English language Abstract of one or more non-English language reference is attached hereto. See References 16-17, 20-22 & 24-26.
- 7. A computer-generated English language translation of one or more Japanese Patent Publication cited herein has been obtained from the website of the Japanese Patent Office ([http://www.jpo.go.jp]), and is attached, but has not been reviewed for accuracy. See References 16-17 & 20-25.

New U.S. National Stage of PCT/JP2004/017099

IAPZDROSEFFIFTO 16 MAY 2006

8. One or more co-pending U.S. patent application is identified on the attached Form PTO 1449. The Examiner is respectfully requested to consider each cited application and the art cited therein during examination of the present application.

9. Reference 1 corresponds to reference 16. Reference 12 corresponds to reference 24.

James A. Oliff

Registration No. 27,075

Daniel A. Tanner, III Registration No. 54,734

JAO:DAT/nxy

Date: May 16, 2006

OLIFF & BERRIDGE, PLC P.O. Box 19928 Alexandria, Virginia 22320 Telephone: (703) 836-6400 DEPOSIT ACCOUNT USE
AUTHORIZATION
Please grant any extension
necessary for entry;
Charge any fee due to our
Deposit Account No. 15-0461

Sheet 1 of 3

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 128029		APPLICATION NO.		
INFORMATION DISCLOSURE STATEMENT					. •	Application		
(Use several sheets if necessary)				APPLICANTS Tatsuhiko HATANO et al.				
				FILING DATE May 16, 2006				
U.S. PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Date		Name			
	1.	2003/0230938 A1	12/18/2003		HATANO et al.			
	2.	2003/0209993 A1	11/13/2003		ITO et al.		_	
	3.	4,740,722	04/26/1988		FURUHATA			
	4.	5,151,762	09/29/1992		UENISHI et al.			
-	5	5,774,348	06/30/1998		DRUCE et al.			
-	6.	3,510,676	05/05/1970		PIERCE			
	7.	3,877,864	04/15/1975		CARLSON			
	8.	3,176,158	03/30/	1965	GUIGNARD			
	9.	3,671,761	06/20/	1972	SHIBUYA et al.			
	10.	3,485,227	12/23/	1969	MEYERLE			
	11.	3,367,314	02/06/	1968	HIROSAWA et al.			
	12.	5,627,741	05/06/	1997	NARUO et al.			
	13.	11/293,324 (Attny Dckt 126712)	12/05/	2005	SEKIYA et al.			
	14.	10/576,253 (Attny Dckt 127737)	04/17/	2006	HATANO et al.			
	15.	11/405,698 (Attny Dckt 127772)	04/17/	2006	HATANO et al.			
		FORI	EIGN PATE	ENT DOC	UMENTS			
Examiner Initials	Cite No.	Document Number		te	Countrý	With English Abstract	With English Translation	
	16.	JP-A-2004-072994	03/04/	/2004	JAPAN	x	х	
-	-		OTHER D	OCUME	NTS			
Examiner Initials								
	1							
EXAMINER	EXAMINER DATE CONSIDERED							
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

Date: May 16, 2006

US Dept. of Commerce ATTY DOCKET NO. APPLICATION NO. Form PTO-1449 128029 New U.S. Patent PATENT & TRADEMARK OFFICE (REV. 1/06) Application INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary) **APPLICANTS** Tatsuhiko HATANO et al. **FILING DATE** May 16, 2006 U.S. PATENT DOCUMENTS Examiner Cite Date Initials Document Number Name No. FOREIGN PATENT DOCUMENTS Cite With With Examiner Initials No. Document Number Date Country English English Translation Abstract 17. JP-A-2002-044965 02/08/2002 **JAPAN** X Х **EUROPE** 18. EP 0 959 562 A1 11/24/1999 GB 2 105 927 A 03/30/1983 UNITED KINGDOM 19. JP-A-2003-272887 09/26/2003 X х 20. JAPAN JP-A-10-76182 03/24/1998 **JAPAN** X x 21. 22. JP-A-11-145793 05/28/1999 **JAPAN** Х Х JP-B2-2649340 05/16/1997 **JAPAN** Х 23. JP-A-08-223915 08/30/1996 **JAPAN** Х х 24. 25. JP-A-2003-338648 11/28/2003 **JAPAN** Х Х OTHER DOCUMENTS Examiner Cite (Including Author, Title, Date, Pertinent Pages, etc.) Initials No. IIDA et al., "Ultra Short-width High-Voltage Pulse Generator"; The Institute of Electrical Engineers of Japan; Plasma 26. Science and Technology, Dept. of Manufacturing Engineering NGK Insulators, Ltd.; Lecture No. PST-02-16.(w/ abstract) 27. JIANG et al., "Compact, High Repetition-Rate Pulsed Power Generator Using High-Speed Si-Thyristor"; IEEE; pp. 602-604; June 30, 2002; Conference Record of the 25th International Power Modulator Symposium and 2002 High-Voltage Workshop: July 30-July 3, 2002. YAMASHITA et al., "High Rep-Rate Inductive-Energy-Storage Pulsed Power Modulator Using High Voltage Static 28. Induction Thyristor"; IEEE; pp. 382-385; June 30, 2002; Conference Record of the 25th International Power Modulator Symposium and 2002 High-Voltage Workshop: June 30-July 3 2002. **EXAMINER** DATE CONSIDERED Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Date: May 16, 2006

Sheet	3	of	3	
011001	_	0.	_	

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 128029		APPLICATION NO. New U.S. Patent Application			
INFORMATION DISCLOSURE STATEMENT							Application	•	
(Use several sheets if necessary)				APPLICANTS Tatsuhiko HATANO et al.					
				FILING DATE May 16, 2006					
		U.	S. PATEN	T DOCUM	MENTS				
Examiner Initials	Cite No.	Document Number	Da	te		Name			
					0.3	=			
	FOREIGN PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Date		Country		With English Abstract	With English Translation	
	-								
		· · · · · · · · · · · · · · · · · · ·							
 			OTHER D	OCUME	NTS .				
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)							
	29.	BOWLES et al., "30 kA, 5000 V Solid State Opening Switch for Inductive Energy Stores"; IEEE; Vol. 20; pp. 249-253;							
June 23, 1992; Proceedings of the Power Modulator Symposium: June 23-25, 1992.									
	30.	ICHIKAWA et al.; "Deposition of a-Si: H Based film by high voltage pulse discharge CVD"; Oyo Buturi; Vol. 61, No. 10;						o. 10;	
	Japan Society of Applied Physics; 1992. (w/ partial trans)								
	31.	NAMIHIRA et al.; "Improvement of NOχ Removal Efficiency Using Short-Width Pulsed Power"; IEEE Transactions on Plasmic							
		Science; Vol. 28, No. 2; pg. 434-442; April 2000.							
			·						
							· .		
			- -						
_		-			· •·				
EXAMINER					DATE CONSIDERED				
Examiner:	Initial if o	citation considered, whether or not citation considered. Include copy of this form wit	on is in co	nformanc	e with M.P.E.P. 609; draw line ton to applicant.	hrough cit	ation if not in	conformance	

Date: May 16, 2006